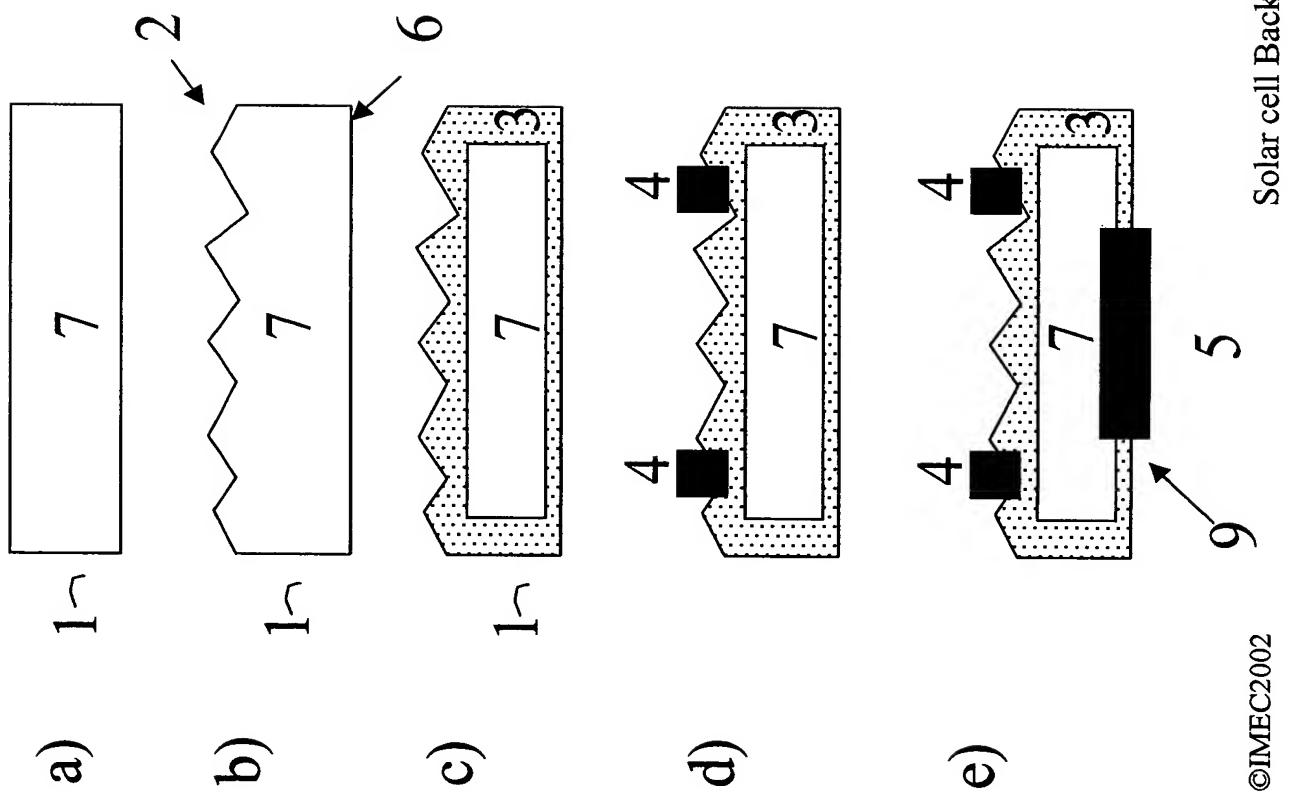
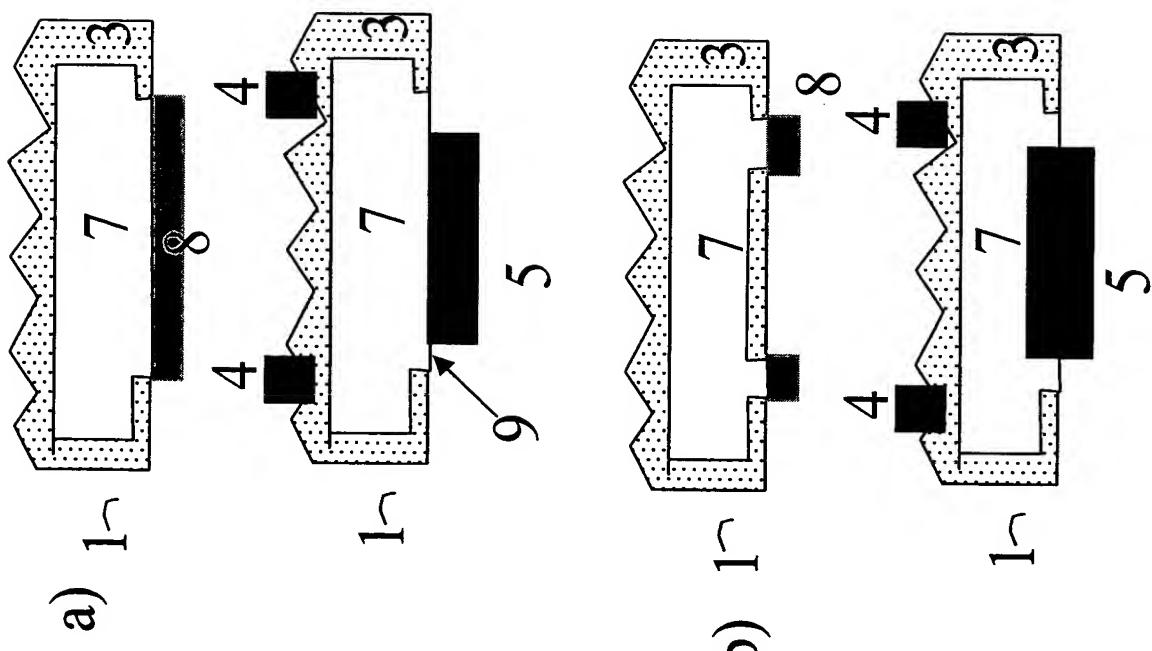


Figure 1: prior art



Appl. No.: Umlarwan
Att'y Doc#: IMEC306.001AUS
Szlufcik, et al.
FOR LOCALISED ETCHING OF SEMICONDUCTOR SUBSTRATES
SEMICONDUCTOR ETCHING PASTE AND THE USE THEREOF

Figure 2: prior art



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SEMICONDUCTOR ETCHING PASTE AND THE USE THEREOF
FOR LOCALIZED ETCHING OF SEMICONDUCTOR SUBSTRATES

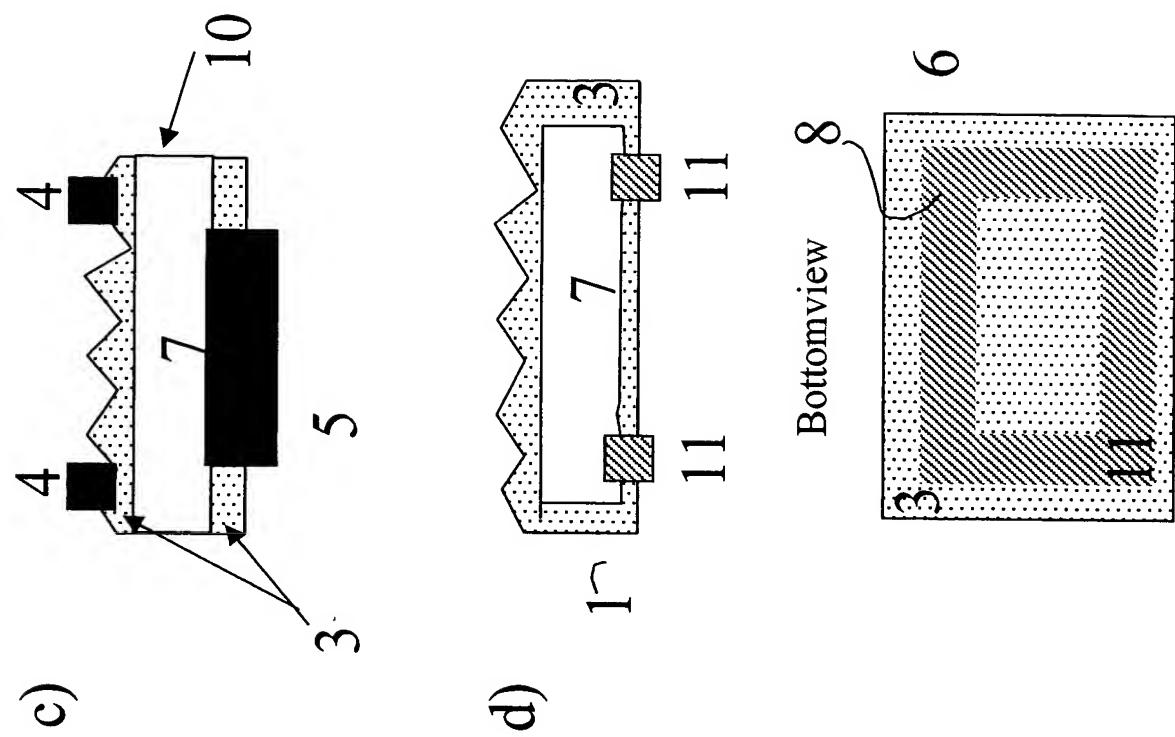


Figure 3:

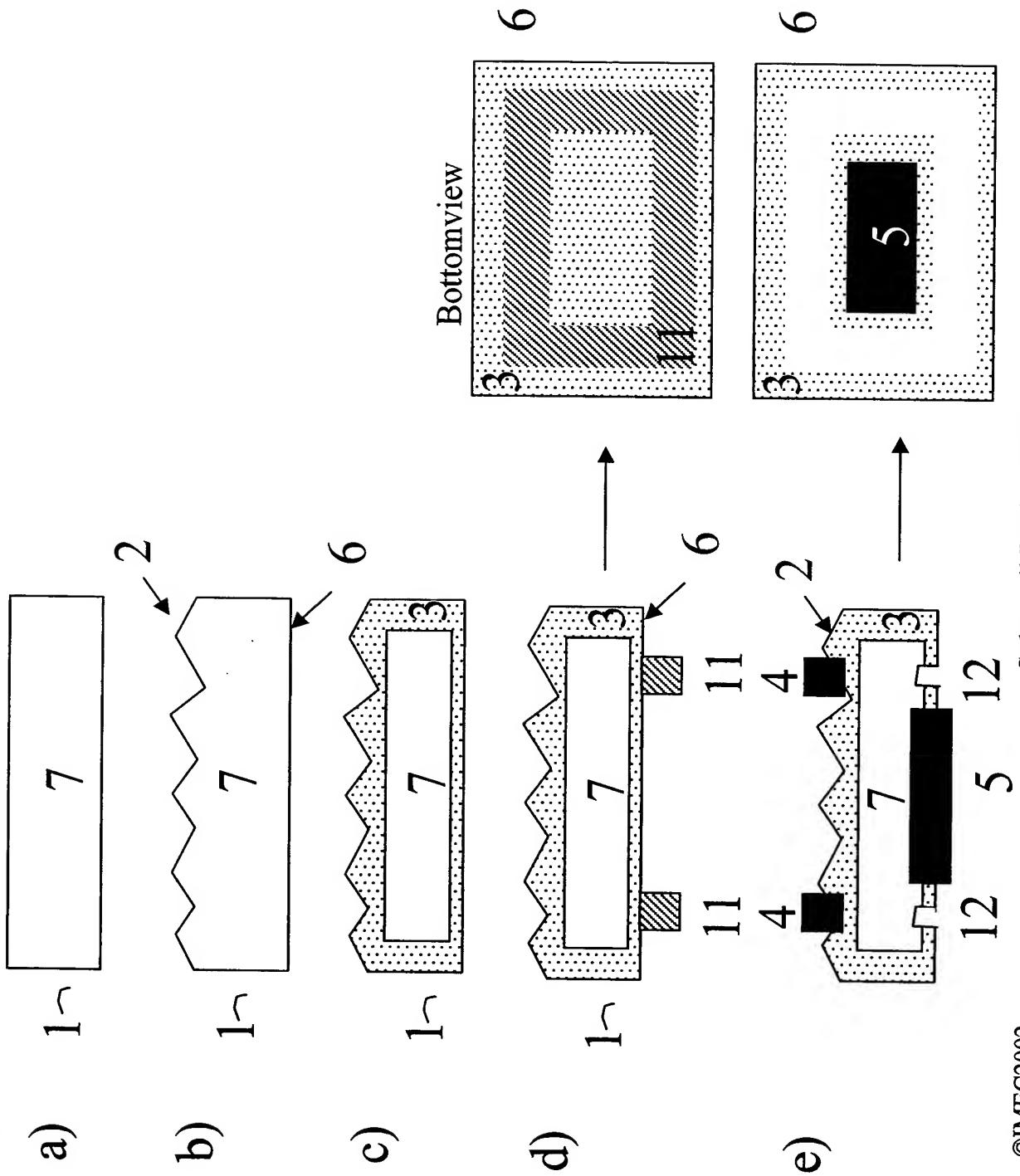
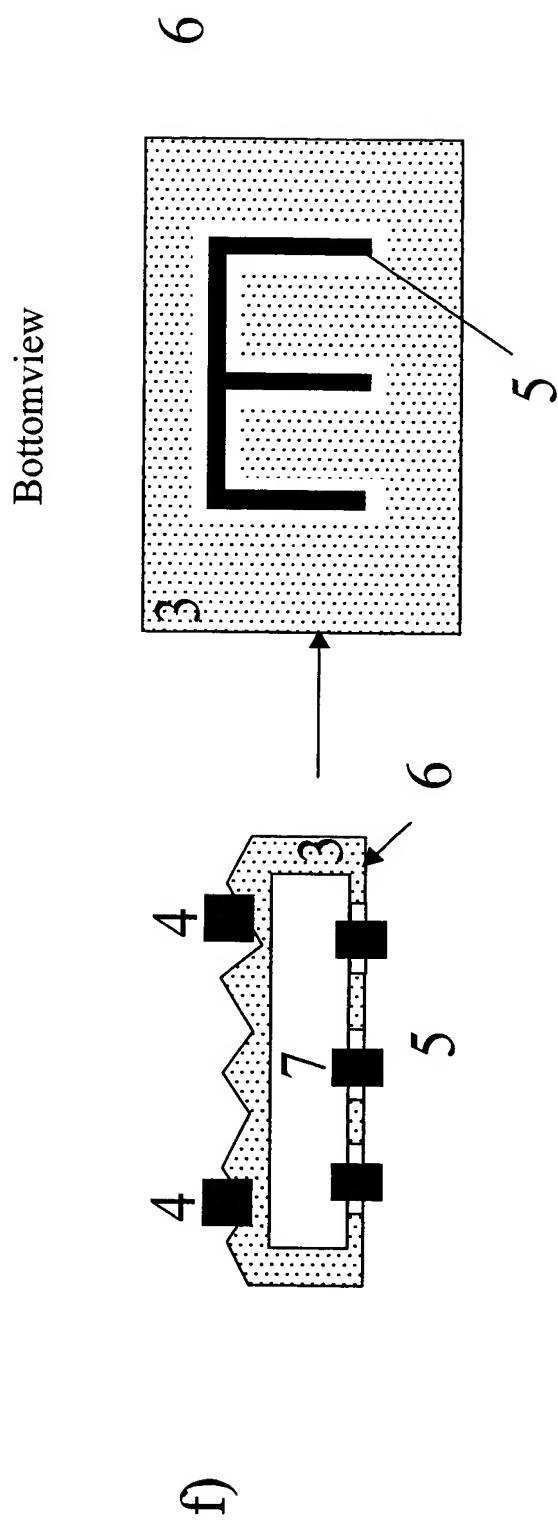
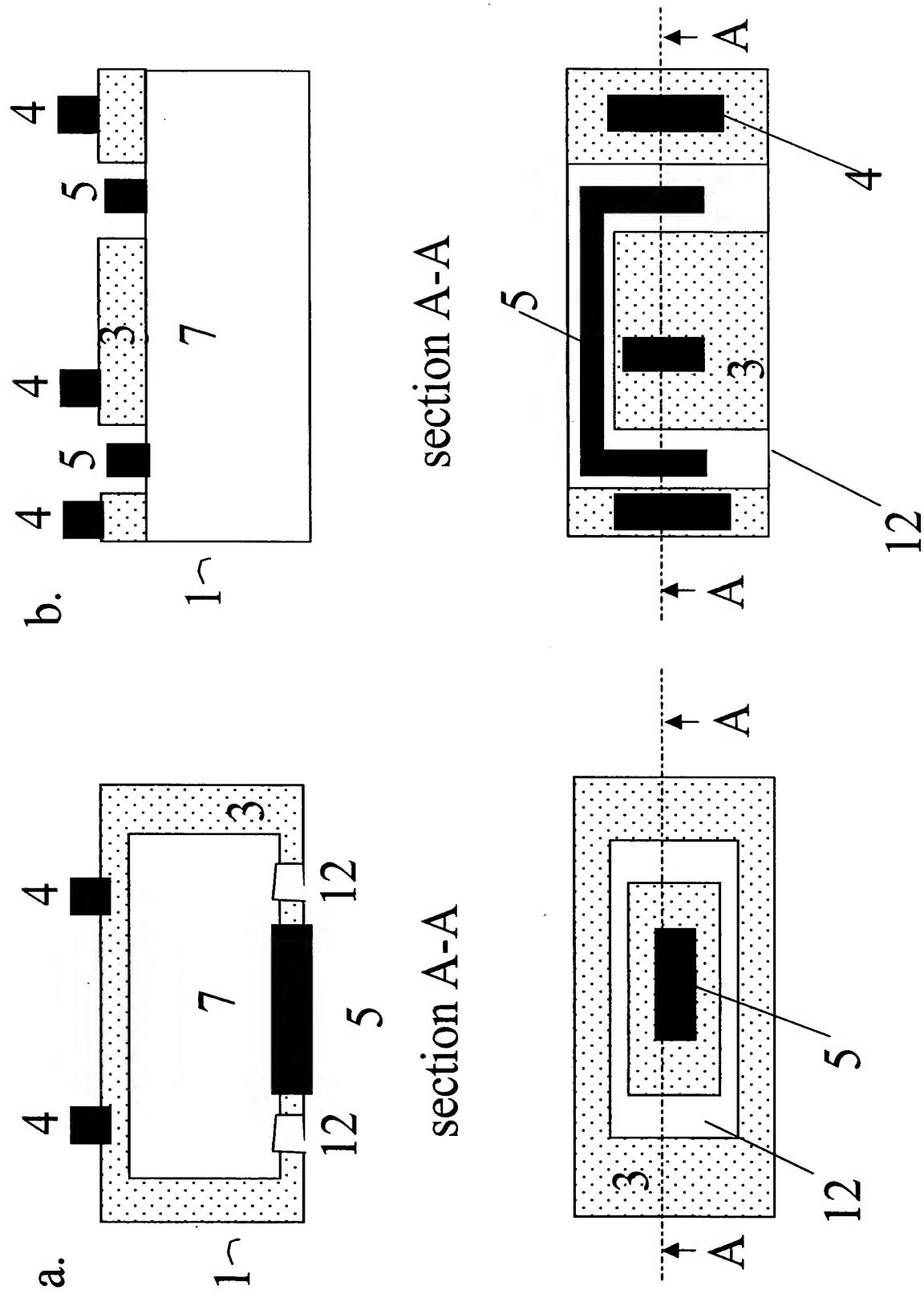


Figure 3:



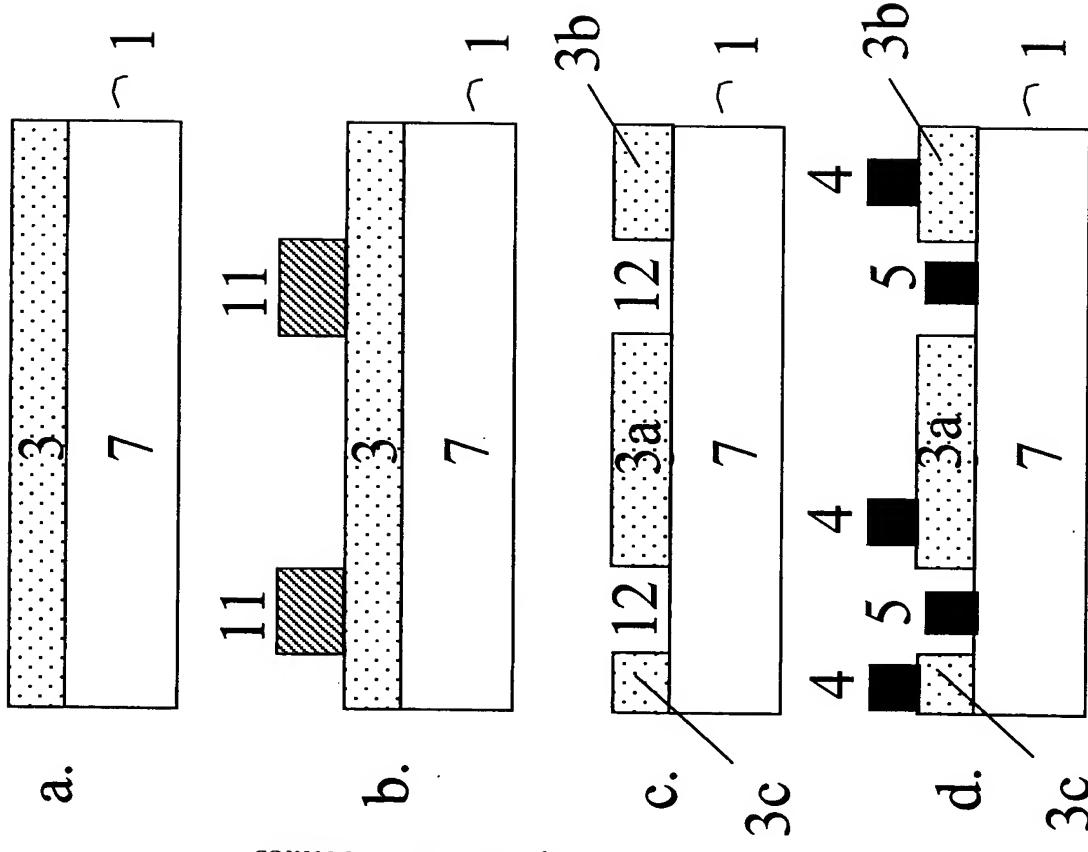
App. No.: Unknown Atty Doc#: IMEC306.001AUS
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FOR LOCALIZED ETCHING OF SEMICONDUCTOR SUBSTRATES
SEMICONDUCTOR ETCHING PASTE AND THE USE THEREOF

Figure 4:



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 FOR LOCALIZED ETCHING OF SEMICONDUCTOR SUBSTRATES
 SEMICONDUCTOR PASTE AND THE USE THEREOF

Figure 5:



SEMICONDUCTOR PASTE AND THE USE THEREOF
FOR LOCALIZED ETCHING OF SEMICONDUCTOR SUBSTRATES
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